K.OTSUKA

CERAMIC RESEARCH AND DEVELOPMENT IN JAPAN

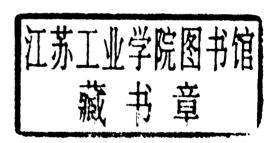
ELSEVIER APPLIED SCIENCE

# Multilayer ceramic substrate-technology for VLSI package/multichip module

### K. OTSUKA

Device Development Center, Hitachi Limited, 2326, Imai Ome-shi, Tokyo 198, Japan

Ceramic Research and Development in Japan





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## Ceramic Research and Development in Japan

Series Editor

### PROFESSOR SHIGEYUKI SOMIYA

Faculty of Science and Engineering
The Nishi Tokyo University
Uenohara-machi
Yamanashi
Japan

## **Foreword**

Dr. Kanji Otsuka graduated from the Department of Ceramics, Kyoto Institute of Technology in 1959 and the following year joined the staff of Hitach Co. Ltd. Since that time, he has worked and developed semiconductors, multilayers ceramic substrate and their devices. This book is one of the results of study by Dr. Kanji Otsuka.

Dr. Kanji Otsuka studied multilayer printed board made with alumina ceramics. Embedded printed wiring of metal was one of the subjects. The attainment of a wiring pattern with high accuracy is described in this book.

It is necessary to be cofired between alumina and tungsten metal powder. Therefore the firing shrinkages between the ceramics and metal powder need to be matched and be simultaneously made up to the final dimensions of design values. These controls are done by the ceramic porocity adjustment. Powder arrangement and the characteristics of bulk density and air permeation in the green forming ceramics should consequently be well under control.

Many parameters underlying this composite structure must be in the optimization. Therefore, quantitative scientific analysis in each process and these relations are needed. This book illustrates this point and leads to a guide line for the fine products.

I recommended him to publish his results as a book style, because this book promotes R & D of multilayer ceramic substrates for semiconductors and computer usage. This book is recommended to students, researchers and engineers in the fields of electronic ceramics, makers and users, all over the world, developed countries and underdeveloped countries because as for starting materials, he used natural raw materials. I am sure this book will prove to be a milestone in the field of ceramic multilayer substrates.

Shigeyuki Sómiya
Dean Professor
The Nishi Tokyo University
Professor Emeritus
Tokyo Institute of Technology

## **Contents**

For	reword		vii	
1	Introd	uction		
	1.1	Introduction	1	
	1.2	Past and current studies	4	
	1.3	Objects and significance of this research	n 9	
2		ling of fine powder mixing and measure	ment of the	
	2.1	Object of this study	11	
	2.2	Study of mixing models	12	
	2.3	Experimental methods	17	
	2.3	2.3.1 Mixing method	17	
		2.3.2 Methods of measurement	18	
	2.4	Result and discussion	22	
	2.7	2.4.1 Decision of sample size	22	
		2.4.2 Sample size and degree of m		
		2.4.3 Mixing speed	25	
		2.4.4 The density of the green mate		
		tion to the degree of mixing	31	
		2.4.5 Sintering density and the		
		mixing	31	
	2.5	Summary	36	
3	Simula	ation of the flowpath in the doctor-blade an	d its applica-	
	tion to	raising the precision of green sheet thick	ness	
	3.1	Object of the study	39	
	3.2	Experimental procedure	40	
		3.2.1 Slurry preparation method	40	
		3.2.2 Forming green sheets	45	
	3.3	Derivation of an equation relating castir	ig conditions	
		and green sheet thickness	47	
	3.4	Experimental results and discussion	53	
	3.5	Improving thickness precision by means of a 2-stage		
		blade	59	
		3.5.1 Derivation of an equation for		
		ing sheet thickness with a 2-		
		3.5.2 Correlation between experi		
		sults and simulation calculation		
		2-stage blade	64	

Contents

	3.6	Preliminary validation of the dimensional stability of green sheets				
		3.6.1	The purpose of the confirmation and experimental methods	69		
		3.6.2	Study of the stability of sheet dimension	05		
			during printing and drying	73		
		3.6.3	Validation of creep characteristics	74		
		3.6.4	Adhesion of sheets with different binder			
	2.7		contents	75		
	3.7	Summary	,	77		
4	Impro	ving dimen	sional precision by firing in a reducing			
	atmos		sional precision by firing in a reducing			
	4.1	_	of the studies	8		
	4.2		ental methods	82		
		4.2.1	Green sheet preparation	82		
		4.2.2	Sample preparation for measurement	83		
		4.2.3	Firing method	83		
		4.2.4	Methods for measuring the various con-	10.00		
			ditions	86		
			4.2.4.1 Observations on the process of	0.4		
			binder decomposition 4.2.4.2 Observation on sintering in	86		
			4.2.4.2 Observation on sintering in ceramics	87		
			4.2.4.3 Measurements of sintering sam-	0/		
			ple characteristics	88		
	4.3	Results	related to binder burn-out and ceramic	00		
			and discussion	91		
		4.3.1	Investigation of the thermal decomposi-			
			tion of the binder burn-out	91		
		4.3.2	Study of the sintering process in this			
			ceramic system without organic binder	95		
		4.3.3	Study of the relationship between binder			
		4.3.4	burn-out and ceramic sintering	97		
	4.4		Summary ionship between the binder burn-out and	101		
	7.7		under varied mixing conditions	103		
		4.4.1	Changes in shrinkage and bulk density	103		
		1, 1, 1	in air firing in green sheets mixed under			
			varied conditions	103		
		4.4.2	Relationship between shrinkage in			
			dimensions and bulk density with firing			
			in a moist reducing gas atmosphere in			
			sheets made under different mixing con-			
		200	ditions	107		
		4.4.3	Changes in the sintering mechanism	17		
			with differing mixing conditions	110		

xi Contents

		4.4.4	The relationship between firing temper-	
			ature and gas permeability in green	
			sheets mixed under different conditions	119
		4.4.5	Discussion of variation in firing shrink-	
			age	120
	4.5	Summary		124
5	Effect	of forming	and firing conditions on the dimensions of	
	ceram			
	5.1	Object of	the study	127
	5.2		ntal method	127
		5.2.1	Preparation of green sheets	127
		5.2.2	Firing conditions	128
	5.3		hip between green sheet thickness and fir-	
			tage or bulk density	131
	5.4		hip between sheet thickness and shrinkage	
			ting direction	133
	5.5		nts on the relationships between furnace	
		structure,	atmosphere and organic binder content,	
		and dime	nsional shrinkage	138
		5.5.1	Effect of water vapour concentration in	
			the firing atmosphere	138
		5.5.2	Binder content and variation in firing	
			shrinkage	139
		5.5.3	Relationship of gas flow rate and loca-	
			tion in the furnace to variation in	
			shrinkage	142
	5.6	Summary		146
		5.6.1	The relationship of dimensions and	
			shrinkage with physical dimensions, fur-	
			nace structure, atmosphere and amount	
			of binder	146
	5.7	Systemati	c consideration of starting material particle	
		size and p	particle alignment in preforming	147
	5.8		c consideration of sheet thickness	154
	5.9		c consideration of ceramic firing conditions	157
	5.10	Overall su	ammary of Chapter 4 and Chapter 5	161
		5.10.1	The mutual relationship between the	
			removal of polyvinyl butyral binder in	
			firing alumina ceramics in an atmos-	
			phere of reducing gas and the sintering	
			of the ceramics	161
6			ength of tungsten metallization on alumina	
	ceram			- 0-
	6.1		of the study	163
	6.2		ntal methods	165
		6.2.1	Starting materials	165
		6.2.2	Preparation of specimens	168

*Contents* xii

	6.3	6.3.1 6.3.2	thickness on bonding strength Effect of alumina content of the ceramics on bonding strength	169 169 170 171 171 171
		6.3.4	Effect of firing conditions on bonding strength	175
		6.3.5	The bending strength after firing of mixed ceramic-tungsten powders  Analysis of the ceramic/metal interface	176
	6.4		by SEM and XMA	180
	0.4	Summary	<b>,</b>	182
7	Study ceram		e aluminium metallization on alumina	
	7.1	Purpose	of the studies	185
	7.2	7.2.1	ental methods Specific preparation	185 185
		7.2.2	Measurement methods (Fig. 7.4)	189
	7.3 7.4	Experime Summary	ental result and discussion	190 195
8		ics, and its	ion between fine metallization on alumina protection  of the study	197
	8.2.		ntal methods	198
		8.2.1	Sample preparation	198
			8.2.1.1 Samples for measuring electrical current leakage	198
			8.2.1.2 Samples forming protecting structures	
		8.2.2	Measurement method	202 202
			8.2.2.1 Measurement of changes in surface state	202
			8.2.2.2 Measurement of the reliability of the protecting structures	203
	8.3	Experimn	tal result and discussion	203
		8.3.1	Changes in surface electrical resistance	203
		8.3.2	Study of protecting structures	207
		8.3.3	Summary	214

Contents

9

Sumr	nary			
9.1	Guideline	es obtain	ed by production process	215
	9.1.1	Formul	lation of ceramic raw materials	
		and org	ganic binders	215
	9.1.2	Dry mi	xing	215
	9.1.3	Additio	on of organic solvents	217
	9.1.4	Wet mi	xing	217
	9.1.5	Casting	and drying	217
	9.1.6		ng registration holes	217
	9.1.7	Printing	g tungsten paste into patterns and	
		drying		217
	9.1.8	Throug	h hole punching	218
	9.1.9	Hot pre	essure lamination	218
		9.1.10	Organic binder burn-out and the	
			firing of ceramics	218
		9.1.11	Additional metallization and	
			metal surface finishing	219
		9.1.12	Protection of metallization pat-	
			tern	219
9.2	Overall s	ummary		219
	Reference	?S		223
	Tu dou			222
	Index			233

# 1 Introduction

#### 1.1 INTRODUCTION

Recent developments in computers, computer peripherals and electronic consumer products owe much to the development of semiconductor devices, namely ICs and LSIs. There have also been considerable developments in the technology for incorporating these LSIs into equipment. Wiring substrates are particularly important as components for connecting semiconductor devices with each other and with input/output devices. To enable high-speed signal exchange, the wiring on wiring substrates needs to be short. In order to achieve this, fine wiring techniques become necessary to decrease the horizontal surface of the wiring substrates; this also fulfils the need for size reduction. The development of highly integrated high performance LSIs also entails the necessity for raising the wiring density of wiring substrates, leading to the wide adoption of multilayer wiring.

Techniques for producing fine and highly integrated (multilayer) wiring substrates have received a lot of effort. Broadly speaking there are two types of so called printed circuits, employing glass-fibre-reinforced epoxy resin boards and copper metallization; and multilayer ceramic wiring substrates, with tungsten or molybdenum metallization on alumina ceramic. The former type is used for applications requiring wiring over a relatively large surface area; the latter type is mainly intended for applications requiring small highly-integrated wiring systems. The upshot of this distinction is that microfine processing is more advanced for the latter type than the former type, and the method for making the latter type is more suited to fine processing. This book is concerned with the latter type-multilayer alumina ceramic wiring substrates, and with syste-

matic studies into improving dimensional precision, and into techniques for metallization.

In making multilayer alumina ceramic wiring substrates, preforms already furnished with metallized wiring are hardened by passing though a firing process. At this time they shrink by 10% or more; in terms of surface area there is a large shrinkage of something under 30%. Variations in this shrinkage are reflected in variations in the dimensions of the finished products, and this hinders the production of high-precision fine wired packages for semiconductors. Because the metallized wiring is also fired, it is necessary to have some means for preventing the oxidization of the metal making up the metallized wiring (firing in a reducing atmosphere), but this also hinders the loss of the organic binder employed when making the preform. In the preform, the ceramics and the metallization are both in the form of powders held firm by binders, and the filled state differs with the particle size of the

Table 1.1. Typical Cermic Materials for the LSI Packages and Boards

Materials		Thermal coefficient of expansion 0-100°C (10 <sup>-6</sup> °C <sup>-1</sup> )	Thermal conductivity (W/m · K)	Dielectric constant/ MHz	Young's modulus (GPa)	Modulus of rupture (MPa)
Alumina	Al <sub>2</sub> O <sub>3</sub> 92-95% SiO <sub>2</sub> ,	6.0-6.5	15-30	8.5-9.5	270-380	300-350
Silicon carbide	MgO etc SiC > 99%	3.5	150-270	40	420	450
Alumin- um nitride	AIN > 99%	4.0	100-170	8.5-9.0	320	450
Mullite	3A1 <sub>2</sub> O <sub>3</sub> .2SiO <sub>2</sub> . SiO <sub>2</sub> , CaO etc		4–6	5-6.8	180	80-200
Glass- ceramics	Borosilicate	3.5-4.0	3–7	5–7	160-200	80-200

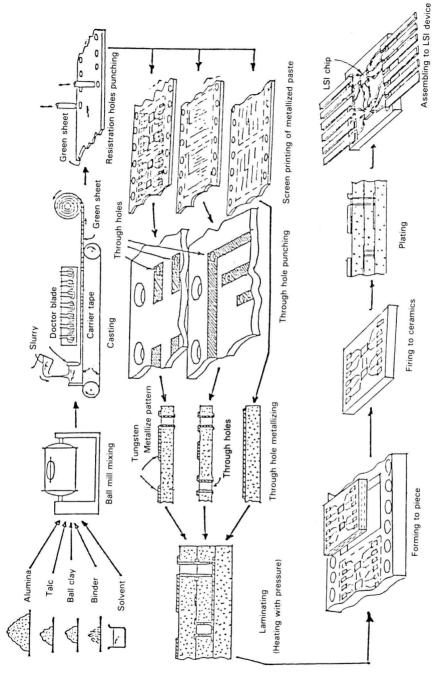


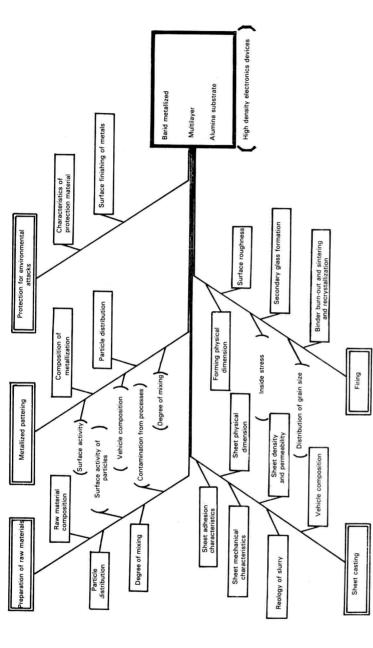
Fig. 1.1. Production Process for multilayer package of LSI's.

powders and the state of mixing. Many factors, such as the sintering reaction of the powder, binding between the ceramic and the metallization, and the degree to which shrinkages are matched, etc., during firing contribute to variations in dimensions. When it comes to optimizing the system as a whole, trade-offs are necessary among these various factors. To date there have been few theoretical or practical studies concerned with these systems as a whole, so this was the main thrust of this research. Because raising dimensional precision affects the strength of metallization bonding, studies were also undertaken on the conditions for obtaining this strength and on the mechanism of bonding. Additional studies concerned suitable ways to protect the insulation of metallization arranged with very small gaps and to prevent it from breaking down.

#### 1.2 PAST AND CURRENT STUDIES

The concept of alumina ceramic multilayer circuit boards was announced by Gyurk and Liederbach (1960), incorporating the current processing method (green sheets being produced using a doctor blade and lamination of sheets with metallized patterns). Since the announcement of this method, this technology has been that normally employed for advanced substrates for semiconductor elements. Stetson and Schwartz (1961) developed this concept, and announced an idea for enabling complex and free wiring bonding, in which wiring, embedded in a layered structure, intersected in three dimensions. Liederbach and Stetson (1961) gave examples of practical applications for this structure; and this concept has continued to the present time. The processes involved in the most common method are shown in Fig. 1.1 and the material possibility is listed in Table 1.1.

A lot of research has subsequently been carried out on improving this method of manufacture, improving the materials, etc. Alm and Miller (1966) proposed a method of copper impregnation, to overcome the drawbacks of molybdenum wiring materials, which cultivate porosity and have high electrical resistance. Schwartz and Wilcox (1967) enumerated the factors that need to be controlled in this method, and discussed the need for design optimization balancing all of these factors, singling out the main factors to control. Thus, by preparing and mixing particulate ceramic starting materials, a binder and a solvent, green sheets like paper are made



protecting structures. 1. Preparation of alumina starting materials; 2. Metallization; 3. Protection from the environment; 4. Startsions and shape; 16. Surface roughness; g. (stresses within the complex); h. (grain size distribution); 17. Slurry rheology; 18. Sheet density and porosity, 19. Amount of glass recrystallization; 20. Vehicle composition; 21. Porosity after burn-out of organic Fig. 1.2. Essential factors in high-precision processing of internal wired multilayered alumina ceramic wiring substrates with ing material composition; 5. Metallization composition; 6. Protecting material characteristics; a. (degree of activity); b. (degree distribution; 8. Metallization particle size; 9. Added metallization characteristics; 10. Degree of mixing; 11. Multilayer alumina ceramic substrates with internal metallized wiring, fitted with a protecting structure f. (devices with high density electronic cirof activity of starting materials); c. (vehicle composition); d. (process contaminants); e. (degree of mixing); 7. Particle size cuits); 12. Sheet adhesion characteristics; 13. Product dimensions and shape; 14. Sheet mechanical properties; 15. Sheet dimenbinder; 22. Sheet processing; 23. Firing.

with a constant controlled porosity. As well as enabling metallizing paste to be printed without blotting, this is also beneficial when it comes to embedding the thickness of the metallized wires in the green sheet during lamination. Changes in porosity are caused by pressure during lamination, and in order to keep the changes uniform it is important to improve the flatness of the green sheets, i.e. improve precision with regard to thickness. By ensuring a constant degree of activation among particles in the aligned state before firing, variations in firing shrinkage can be kept within  $\pm 1\%$ . Metallizing materials are chosen which have a similar firing shrinkage and coefficient of thermal expansion to those of the ceramic, and which react well (sinterability) with the ceramic. Firing is carried out in a reducing atmosphere so as to prevent the oxidation of the metallization, and sintering is carried out after burning out the organic binder. And the control of particle size and pore size in the ceramic is important for obtaining stable firing shrinkage and strength. However, Schwartz and Wilcox do not deal in any way with quantitative aspects. The factors which are generally controlled at the present time, including the suggestions of Schwartz and Wilcox, are summarized in Fig. 1.2. Everett (1969) reported that with the above method the variation in firing shrinkage could be kept to  $\pm 1\%$ , and that fine wiring 100  $\mu$ m wide could be printed, but there are no reports that this has actually been achieved. Keeping the variation in firing shrinkage small leads to improvements in the dimensional precision of the finished multilayer substrates (precision in the relative positioning of the wires), and is an important factor when it comes to making high-precision multilayer substrates, but in more than 20 years since the publication of these reports there have been no reports directly concerning the stabilization of shrinkage.

The inventor of the concept, Gyurk (1960), pointed out that substrate firing should be carried out in an atmosphere of reducing gas with water vapour to keep a balance between the promotion of binder burn-off and the prevention of metal oxidization, but he did not establish a firing temperature curve. Finch (1960) reported that binder burn-off required holding at a temperature of 600°C. It is now widely recognized that binder burn-off is difficult to accomplish in a reducing atmosphere, and this is one factor which causes large variations in firing shrinkage. Use of platinum metallization to enable firing in an oxidizing atmosphere was proposed by Keller, Pirigyi, Cole and Budd (1969). This approach had the advantage of

burning the binder off easily and keeping variations in firing shrinkage low; however, it has not been used in practice because of the high cost of platinum. Chance (1970) showed that when tungsten metallization was fired the whole substrate was put under a strain by differences in shrinkage, and he investigated the effects of matching shrinkages on the strength of bonding between the metallization and the ceramic. Wilcox (1971) investigated the pros and cons of the selection of a wide variety of ceramic materials and metallization materials, and concluded that alumina and bellyria ceramics, and molybdenum and tungsten metallization were most suitable. He also reported that these materials were more suitable than epoxy-resin printed circuits or thick film wiring substrates for fine wiring, enabling wire widths of 100 μm, through holes 100 μm in diameter, and virtually infinite lamination. This is generally acknowledged at the present time. Finch, Kaiser, Pakulski and Reardon (1970) proposed the concept of continuous manufacture of multilayer wiring substrates (loop conveyor belt process).

Surtani (1971) reported that the air-tightness of Mo/Mn metallization on alumina ceramics was completed by permeation of the metallization layer by a glass matrix formed from the alumina ceramic. Because it is necessary for the metallization in multilayer substrates to be firmly secured when it comes to soldering on the external connecting pins, this research, together with that of Chance mentioned above, includes many indications for future research.

Hargis (1971) suggested that at that time the actual variation in firing shrinkage was  $\pm 1\%$ , but that it was possible to decrease it to  $\pm 0.5\%$  by optimizing the different manufacturing processes. However, they did not make any concrete proposals as to optimum conditions. Shanefield and Mistler (1971) were the first to reveal the doctor-blade method for making thin ceramic sheets (green sheets); the method which they proposed was similar to that used today. They also obtained a variation of  $\pm 0.5\%$  in firing shrinkage (not including metallization). Shanefield and Mistler (1974) also reported that for avoiding the agglomeration of powdered ceramics in mixtures with organic solvents it is important to add a defloculating agent, and that fish oil is suitable for this purpose.

Gardner and Nufer (1984) investigated the mechanical properties of green sheets and clarified the relationships among effective solvent permeability with respect to metallization printing, deformation during lamination, each of punching holes, and binder content.